

Chemicals contained in products

Package-type

Epson Package name; **QFP15-128PIN**

JEITA Package name; **P-LQFP128-1414-0.40**

Lead frame plating; **Lead(Pb) Free**

Weight; **0.69 [g]** *Note1

Part	Subpart	Subpart weight [mg]	Substance name	CAS No.	Content *Note2		Application
					[mg]	[ppm]	
IC Die	IC Die	14	Silicon	7440-21-3	13.6	999894	Base material
			Boron	7440-42-8	0.00003	2	Dopant
			Phosphorus	7723-14-0	0.0001	5	Dopant
			Aluminum	7429-90-5	0.0003	20	Metalization
			Arsenic *Note3	7440-38-2	0.0001	5	Dopant
			Fluorine *Note3	7782-41-4	0.00003	2	Dopant
			Titanium *Note3	7440-32-6	0.0003	20	Metalization
			Molybdenum *Note3	7439-98-7	0.0003	20	Metalization
			Tungsten *Note3	7440-33-7	0.0004	30	Metalization
			Cobalt *Note3	7440-48-4	0.00003	2	Metalization
	Stress buffer coat	0.27	Polyimide	-	0.27	1000000	Stress buffer coat *Note4
Package	Die Bonding material	3.0	Silver	7440-22-4	1.9	640000	Base material
			Epoxy resin	-	0.63	205000	Adhesive
			Phenol resin	-	0.24	80000	Adhesive
			Inorganic powder	-	0.14	48000	Additive
			Bismuth compound	-	0.08	27000	Ion trap
	Lead Frame Plating	15	Tin	7440-31-5	14.6	980000	Solder
			Bismuth	7440-69-9	0.30	20000	Solder
	Lead Frame	180	Copper	7440-50-8	170	945000	Conductor
			Silver	7440-22-4	0.90	5000	Inner lead plating
			Others *Note5	-	9.0	50000	Additive
	Bonding Wire	3.0	Gold	7440-57-5	3.0	1000000	Conductor
	Mold resin	475	Epoxy resin	-	52.3	110000	Base material
			Antimony trioxide	1309-64-4	3.8	8000	Flame retardant
			Halogenated compound(Brominations epoxy)	-	3.8	8000	Flame retardant
			Silica	60676-86-0/-	358	753500	Filler
Carbon black			1333-86-4	4.7	10000	Coloring agent	
Hardening chemical(ex:Phenol resin)			-	52.3	110000	Base material	
Organic phosphorous compound			-	0.24	500	Hardening accelerator	

Regarding the information of chemical substances

*Note1 The weight might be somewhat different depending on an individual built-in IC-chip specification like the size etc.

*Note2 Content data are estimated values based on supplier information and intended levels of content in product.

Actual measurements may vary from these values somewhat.

*Note3 Use or not-use of these substances depends on individual built-in IC-chip specification.

*Note4 The stress buffer coat may not be used depending on the individual model.

*Note5 The nickel, zinc, tin, silicon, iron, and the zinc oxide are included for the Cu type. And the carbon, silicon, and manganese are included for 42alloy type.